

The influence of graphene curvature on hydrogen adsorption

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Outline

- Why graphene and hydrogen?
- The role of graphene curvature from theoretical calculations
- Finding a suitable graphene system with intrinsic curvature
- Characterizing the samples
 - Raman spectroscopy
 - Scanning tunneling microscopy
- Hydrogenating the samples
- Dehydrogenating the samples
- Conclusions



What is graphene?

A SINGLE sheet of carbon atoms.

The atoms are arranged in a honeycomb lattice composed of two intertwined equivalent sublattices.







Possible to change the electronic properties by H adsorption.

Open a band gap of 3.5eV. (Sofo (2007))

Possibly useful for hydrogen storage.

We are interested in the interaction of hydrogen as a function of local curvature since graphene is a flexable membrane.



J. O. Sofo et al. Phys. Rev. B 75, 153401 (2007)



Graphene + Hydrogen →Graphane

Chemisorption: Formation of a covalent chemical bond between the hydrogen atoms and the scaffold.

Adsorption of hydrogen opens a bandgap of 3.5eV.

J. O. Sofo et al. Phys. Rev. B 75, 153401 (2007)

First experimental evidence of hydrogen adsorption on graphene in 2009. D.C. Elias et al. Science 323 5914 (2009)

EXPLORE THE INTERACTION OF GRAPHENE CURVATURE FOR HYDROGEN ADSORBTION AND RELEASE



J. O. Sofo et al. Phys. Rev. B 75, 153401 (2007)



V. Tozzini and V. Pellegrini, Journal Physical Chemistry C **115**, 25523 (2011) The hydrogen binding energy on graphene is strongly dependent on local curvature and it is larger on convex parts



Finding a suitable graphene system to test the interaction of hydrogen and graphene as a function of curvature

Monolayer graphene on SiC(0001)

Buffer layer on SiC(0001)

Quasi-free-standing monolayer graphene on SiC(0001)

CNRNANO Graphene on SiC(0001)



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Buffer layer

SiC

Buffer layer Topologically identical atomic carbon structure as graphene. Does not have the electronic band structure of graphene due to periodic sp³ C-Si bonds.





F. Varchon, et al., PRB 77, 235412 (2008).

Superperiodicity of both the Buffer layer (Δz =120pm) and monolayer (Δz =40pm) graphene on the Si face from the periodic interaction with the substrate.



Graphene growth on SiC(0001)





Quasi-free-standing monolayer graphene (QFMLG)

Buffer layer



QFMLG







Hydrogen intercalation of the buffer layer and ARPES

Buffer layer







Material Characterization

Monolayer graphene on SiC(0001)

Buffer layer on SiC(0001)

Quasi-free-standing monolayer graphene on SiC(0001)

Techniques

Raman spectroscopy

Scanning Tunneling Microscopy





Raman spectrum on monolayer graphene SiC(0001)

Intensity map of 2D peak





STM image of monolayer graphene on SiC



Bias = 115mV, Current = 0.3nA



Scanning tunneling spectroscopy (STS) of monolayer graphene on SiC





Bias = -0.292V, Current = 0.3nA



Raman spectrum on buffer layer SiC(0001)





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STM image of buffer layer on SiC





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STM image of buffer layer on SiC





STS of buffer layer on SiC





Raman spectrum on quasi-freestanding monolayer graphene



STM image quasi-free standing monolayer graphene on SiC

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Summary of graphene systems

Monolayer on SiC(0001)

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Peak to Peak corrugation: ~40pm Periodicity: ~2nm Bonds to substrate: no

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Buffer layer on SiC(0001)

Peak to Peak corrugation: ~110pm Periodicity: ~2nm Bonds to substrate: yes



Quasi-free-standing monolayer graphene

Peak to Peak corrugations: ~40pm from atomic contribution

Periodicity: none Bonds to substrate: no





Hydrogenation Experiments



Experiments on monolayer graphene

Parameters

Atomic hydrogenation parameters: Chamber base pressure: 5 x 10⁻¹⁰ mbar Atomic hydrogen flux: 5.1 x 10¹² atoms/cm²s Sample temperature: Room temperature

Experiments

STS measurements after atomic hydrogen exposure for 5, 25 and 145 seconds.

STM imaging after 5 second hydrogenation and subsequent heating in steps of 50°C for 5 minutes followed by STM imaging after each heating to observe at what temperature the hydrogen desorbs.



STS on monolayer graphene as a function of atomic hydrogen exposure time





Experiments on monolayer graphene

Parameters

Atomic hydrogenation parameters: Chamber base pressure: 5 x 10⁻¹⁰ mbar Atomic hydrogen flux: 5.1 x 10¹² atoms/cm²s Sample temperature: Room temperature

Experiments

STS measurements after atomic hydrogen exposure for 5, 25 and 145 seconds.

STM imaging after 5 second hydrogenation and subsequent heating in steps of 50°C for 5 minutes followed by STM imaging after each heating to observe at what temperature the hydrogen desorbs.



STM image of monolayer graphene after atomic hydrogen exposure of 5 seconds

Before Hydrogenation



After Hydrogenation



Bias = 115mV, Current = 0.3nA

Bias = 50mV, Current = 0.3nA



Identifying stable hydrogen configurations on monolayer graphene Paradimer Orthodimer Tetramer

STM Images DFT Calculations V. Tozzini

> STM imaging parameters at Bias = 50mV, Current = 0.3nA S. Goler, et al. J. Phys. Chem. C, 117: 11506-11513, 2013.



Tetramer on monolayer graphene after 5 second hydrogenation



Bias = 50mV, Current = 0.3nA

V. Tozzini

C-H bond length is expected to be 1.1Å and instead we measure 50pm. Carbon atom is slightly more electronegative than hydrogen pulling the electronic wavefunction towards the graphene surface. Agreement with theory. S. Goler, et al. J. Phys. Chem. C, 117: 11506-11513, 2013.

Heating the monolayer graphene

ШZ

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Heated to 630°C

Heated to 680°C

Heated to 420°C

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Estimating the desorption energy barrier from Arrhenius equation

$$\frac{E_d}{kT_m} = A \tau_m e^{\frac{-E_d}{kT_m}}$$

E_d = 2.8eV/molecule or 1.4eV/atom

$$\begin{split} & \mathsf{E}_{\mathsf{d}} = \mathsf{Desorption\ energy\ barrier} \\ & \mathsf{k} = \mathsf{Boltzman's\ constant\ (8.617\ x\ 10^{-5} eV/K)} \\ & \mathsf{T}_{\mathsf{m}} = \mathsf{Temperature\ of\ desorption\ (650^\circ C,\ \ 930K)} \\ & \mathsf{A} = \mathsf{Arrhenius\ constant\ (10^{13} s^{-1})} \\ & \mathsf{\tau}_{\mathsf{m}} = \mathsf{Heating\ time\ (10^3 s)} \end{split}$$





Summary of results

- Thorough characterization of buffer layer, monolayer and quasi-free-standing monolayer graphene on SiC(0001).
- First clear atomic resolution STM images of the buffer layer.
- Preferential adsorption of atomic hydrogen on locally convex areas of graphene.
- First observation of dimers and tetramers on graphene on SiC(0001).
- The atomic hydrogen on the maximally convex areas is stable up to ~650°C and agrees with the DFT calculations for the desorption energy barrier of ~1.4eV.
- The graphene layer is not destroyed following multiple hydrogen exposure and heating cycles.



People who contributed to this work

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- Fabio Beltram¹
- Camilla Coletti^{2,3}
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Thank you